

Serial No.: 10/575,338
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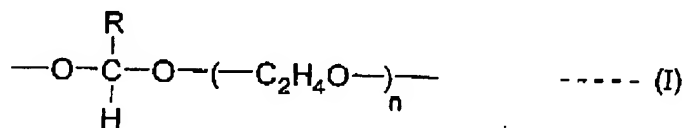
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Amendments to the Claims:

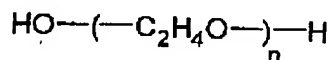
This listing of claims will replace all prior versions, and listings, of claims in the application:

Claims 1. to 5. (canceled)

6. (currently amended) A chemically amplified photosensitive resin composition comprising (A) an alkali-soluble novolak resin, (B) a resin or compound which in itself is insoluble or slightly soluble in alkali, but becomes soluble in alkali by the action of an acid, (C) an acid generating agent, (D) a photosensitizing agent containing a quinonediazide group and being obtained by reacting a halide quinonediazidesulfonate with a low molecular-weight compound or a high molecular-weight compound having a functional group which can be condensed with the acid halide thereof, (E) an alkali-soluble acrylic resin and (F) a compound containing at least two vinyloxyalkylester groups, wherein said resin or compound which is itself insoluble or slightly soluble in alkali, but becomes soluble in alkali by the action of an acid has a structural unit represented by the general formula (I):



wherein R represents a saturated alkyl group having 3 to 10 carbon atoms and n is an integer from 1 to 10, said structural unit represented by the general formula (I) obtained by reacting RCHO, RCH(OH)₂, or RCH(OR¹)₂, wherein R is defined above, and R¹ represents an alkyl group, with



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wherein n is defined above, further where the ratio by weight of said components (A) : (B) : (C) : (D) : (E) : (F) is 100 : 1 to 50 : 0.02 to 10 : 1 to 4 : 0 to 200 : 1 to 30.

Claims 7. to 20. (canceled)

21(previously presented). The chemically amplified photosensitive resin composition according to Claim 6, where the alkali-soluble acrylic resin contains a structural unit derived from a (meth)acrylic acid, a structural unit derived from an alkylmethacrylate and, as required, a structural unit derived from styrene.

22(previously presented). The chemically amplified photosensitive resin composition according to Claim 6, where the alkali-soluble acrylic resin contains a structural unit derived from a hydroxyalkylmethacrylate, a structural unit derived from an alkylmethacrylate and, as required, a structural unit derived from styrene.